

79. An apparatus according to Claim 78, wherein said pair of mirrors includes a total reflection mirror.

REMARKS


Applicants request favorable consideration and allowance of the subject application in view of the preceding amendments and the following remarks.

Claims 1, 2, 4-8, 10-15, 17-29, and 66-79 are presented for consideration. Claims 1, 13, 20, 66 and 73 are independent. Claims 30-65 have been canceled without prejudice or disclaimer.

Pending claims 1, 2, 4-8, 10-15 and 17-29 were previously allowed in this application. In addition to these claims being allowable, Applicant submits that claims 66-79 patentably define features of the gas laser device and the exposure apparatus of the present invention. Therefore, Applicants submit that the instant application is in condition for allowance. Favorable consideration and an early Notice of Allowance are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address listed below.

Respectfully submitted,


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JUL 29 2002
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